Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	jp-07027886-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/03/02 10:50
L2	2	2001jp-0153326.ap,prai.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/03/02 10:52
L3	4	((rie etch\$6) with (low adj temperature)) with ((below less) near (zero degree celsius))	US-PGPUB; USPAT	OR	ON	2005/03/02 10:54
L4	275	438/978.ccls.	US-PGPUB; USPAT	OR	OFF	2005/03/02 10:56
L5	12	("20020151179" "20030059994" "20030113978" "4061530" "4814041" "5196376" "5256248" "6251734" "6313019" "6329109" "6432832" "6541360").PN. OR ("6858542").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/02 11:14
L6	73	(semiconductor wafer silicon substrate) and (pattern\$4 resist photoresist lithograph\$7 photolithograph\$7) and ((hole open\$4 aperture) same (taper\$3 isotropic\$6 slant\$4 angl\$4) same mask\$4 same ((organic flare silk polyimide) with (dielectric insulat\$4)))	US-PGPUB; USPAT	OR	ON	2005/03/02 11:43
L7	155	(438/620.ccls. 438/637.ccls. 438/640.ccls. 438/669.ccls. 438/671.ccls. 438/673.ccls. 438/780.ccls.) and ((semiconductor wafer silicon substrate) and (pattern\$4 resist photoresist lithograph\$7 photolithograph\$7) and ((hole open\$4 aperture) same (taper\$3 isotropic\$6 slant\$4 angl\$4) same mask\$4 same (organic flare silk polyimide dielectric insulat\$4)))	US-PGPUB; USPAT	OR	ON	2005/03/02 13:12
L8	81	(pattern\$4 resist photoresist lithograph\$7 photolithograph\$7) and ((hole open\$4 aperture) with (taper\$3 isotropic\$6 slant\$4 angl\$4)) and mask\$4 and (organic flare silk polyimide)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/02 13:27
L9	10	(dual adj hard adj mask) with organic	US-PGPUB; USPAT	OR	ON	2005/03/02 13:35

L10	88	dual adj hard adj mask	US-PGPUB; USPAT	OR	ON	2005/03/02 13:41
L11	13	"5981913".URPN.	USPAT	OR	OFF	2005/03/02 13:49
L12	0	"6649517".URPN.	USPAT	OR	OFF	2005/03/02 13:50
L13	915	(438/620.ccls. 438/637.ccls. 438/640.ccls. 438/669.ccls. 438/671.ccls. 438/673.ccls. 438/780.ccls.) and (hole open\$4 aperture) and (taper\$3 isotropic\$6 slant\$4 angl\$4) and (mask\$4 resist photoresist)	US-PGPUB; USPAT	OR	ON	2005/03/02 13:50
L14	. 0	("6743712").URPN.	USPAT	OR	OFF	2005/03/02 14:07
L15	11	("5913148").URPN.	USPAT	OR	OFF	2005/03/02 14:07
L16	4	("6387798").URPN.	USPAT	OR	OFF	2005/03/02 14:14
L17	4	"5677242".pn. "6649517".pn. "6548347".pn. "5750441".pn.	US-PGPUB; USPAT	OR	OFF	2005/03/02 14:14
L18	20	("20020000596" "20020102863" "20020132397" "5597763" "5654570" "5677563" "5786250" "5977601" "6133599" "6136716" "6215690" "6225203" "6297090" "6365454" "6368988" "6372651" "6399433" "6429106" "6451649" "6451651").PN. OR ("6548347").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/02 14:19
L19	24	("4269654" "4532005" "4615782" "4699870" "4758305" "4806199" "4814041").PN. OR ("5750441"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/02 14:23